

FORM PTO-1449/A and B (Modified)

APPLICATION NO.: 09/676,251

ATTY. DOCKET NO.: 00428/7090

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

FILING DATE: September 29, 2000

APPLICANT: Vadala et al.

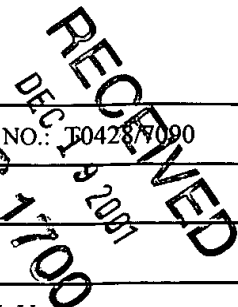
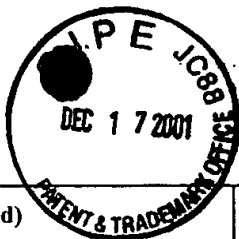
GROUP ART UNIT: 1771

EXAMINER: H. 78

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Examiner's Initials#	Cite No.	U.S. Patent Document		Name of Patentee or Applicant of Cited Document	Date of Publication or of issue of Cited Document MM-DD-YYY
		Number	Kind Code		
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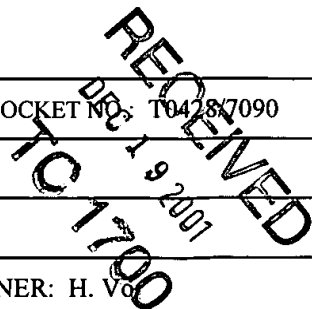
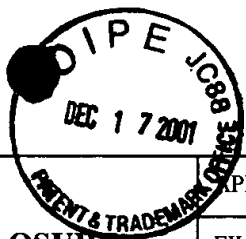
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				GROUP ART UNIT: 1771		EXAMINER: H. Vo	
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	55	EP	0 228 016	A1	Union Carbide Corporation	08.07.87	—
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OTHER ART — NON PATENT LITERATURE DOCUMENTS

Examiner's Initials#	Cite No	Include name of the author (in CAPITAL LETTERS) title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, relevant page(s), volume-issue number(s), publisher, city and/or country where published.	Translation (Y/N)
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EXAMINER <i>Kai V.</i>	DATE CONSIDERED <i>12/31/01</i>
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#EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

*a copy of this reference is not provided as it was previously cited by or submitted to the office in a prior application, Serial No. _____, filed _____, and relied upon for an earlier filing date under 35 U.S.C. 120 (continuation, continuation-in-part, and divisional applications).

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